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thin solid films

Contents

Foreword xi

Fundamentals of thin film growth

Modelling of thin films via a semiempirical method
G. Bozzolo and J. Ferrante 1

Molecular mechanics simulation of the diamond nucleation and growth on silicon (001) and (111) surfaces
R.Q. Zhang, W.L. Wang, J. Estevea and E. Bertran 6

Defects and energy accommodation in epitaxial sputter deposited Mo/W superlattices studied by molecular dynamics
M.H. Carlberg, V. Chirita and E.P. Münger 10

Anisotropic growth of Au and Ag on (001) WTe_2 and β-$MoTe_2$ surfaces between 350 and 700 K
S.W. Hla, V. Marinković and A. Prodan 14

Surface roughness of strain-relaxed $Si_{1-x}Ge_x$ layers grown by two-step growth method
H. Iwano, K. Yoshikawa, S. Zaima and Y. Yasuda 17

In situ observation of microstructural changes of embedded silver particles
A. Heilmann and J. Werner 21

Fundamental structure forming phenomena of polycrystalline films and the structure zone models
P.B. Barna and M. Adamik 27

Investigation of the kinetics of crystallisation of Al/a-Ge bilayer by electrical conductivity measurement
I. Kovács, P. Harmat, A. Sulyok and G. Radnóczi 34

Morphological analysis of discontinuous and semicontinuous metal films
R. Hrach, S. Novák, D. Novotný and J. Pavlík 39

Surface melting of aluminum
F. de Landa Castillo Alvarado, J.H. Rutkowski, A. Urbaniak-Kucharczyk and L. Wojtczak 43

Effects of atomic hydrogen on growth behavior of Si films by Si_2H_6-source molecular beam epitaxy
Y. Yasuda, T. Matsuyama, K. Sato, M. Kondo, H. Ikeda and S. Zaima 48

Growth and characterization of $AlAs_ySb_{1-y}$ and $InAs_ySb_{1-y}$ thin films on GaAs and InAs substrates
Š. Németh, B. Grietens and G. Borghs 52

Study of Ni–Al interface formation
A. Arranz and C. Palacio 55

Atomic force microscope study of the early stages of NiO deposition on graphite and mica
C. Morant, L. Soriano, J.F. Trigo and J.M. Sanz 59

Columnar structures in polycrystalline thin films developed by competitive growth
M. Adamik, P.B. Barna and I. Tomov 64

Fractal behaviour of the surface of in situ heat treated metal–InP contacts
I. Mojzes, B. Kovács, M. Schuszter, I. Kun, L. Máté, L. Dobos and L. Dávid 69

TEM study of Ag_2Se developed by the reaction of polycrystalline silver films and selenium
G. Sáfrán, O. Geszti, G. Radnóczi and P.B. Barna 72

AES and EELS study of aluminium oxide thin films
R. Kapsa, I. Stará, D. Zeze, B. Gruzza and V. Matolín 77

Simulation of epitaxial growth of CeO_2 on YSZ(100) and $SrTiO_3$ on MgO(100) for $YBa_2Cu_3O_{7-x}$ deposition
R. Aguiar, F. Sánchez, C. Ferrater, M. Aguiló and M. Varela 81

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Thin film characterisation and deposition techniques

In-situ analysis of particle contamination in magnetron sputtering processes
G.S. Selwyn, C.A. Weiss, F. Sequeda and C. Huang 85

Preparation of TiN_x thin films using r.f.–d.c. coupled magnetron sputtering in $Ar–N_2$ gas plasma
T. Tanaka and K. Kawabata 93

Preparation and structure of AlW thin films
N. Radić, A. Tonejc, M. Milun, P. Pervan, J. Ivkov and M. Stubičar 96

AlN thin films prepared by ion beam induced chemical vapour deposition
J.C. Sánchez-López, L. Contreras, A. Fernández, A.R. González-Elipe, J.M. Martin and B. Vacher 100

Preparation of $Hg_{1-x}Cd_xTe$ $(0.1 \leq \times \leq 0.5)$ epitaxial layers by two-stage evaporation–condensation–diffusion method
V.G. Savitsky and O.P. Storchun 105

Study of material emission in ArF and KrF excimer laser ablation of yttria stabilized zirconia single crystals
F. Sanchez, R. Aguiar, P. Serra, M. Varela and J.L. Morenza 108

Influence of the substrate temperature on silicon–carbon thin films deposited from SiH_4 and C_2H_4 by excimer lamp–CVD
X. Redondas, P. González, B. León and M. Pérez-Amor 112

Deposition of low temperature Si-based insulators by the electron cyclotron resonance plasma method
S. Garcia, J.M. Martin, I. Martil, M. Fernandez and G. Gonzalez-Diaz 116

Optical emission spectroscopy of rf glow discharges of methane–silane mixtures
J.L. Andújar, E. Pascual, G. Viera and E. Bertran 120

Deposition and characterization of multilayered TiN/ZrN coatings
C.J. Tavares, L. Rebouta, B. Almeida, J. Bessa e Sousa, M.F. da Silva and J.C. Soares 124

Spectroscopic characterization of thin solid films of 1,3 bis(3- chlorobenzylimido perylene) propane
S. Rodriguez-Llorente, R. Aroca, J. Duff and J.A. de Saja 129

Optical constants of thin films by means of a pointwise constrained optimization approach
I. Chambouleyron, J.M. Martínez, A.C. Moretti and M. Mulato 133

Formation and evaluation of CeN thin films
S.Q. Xiao and O. Takai 137

Undoped and doped crystalline silicon films obtained by Nd-YAG laser
I. Ferreira, J. Carvalho and R. Martins 140

Investigation of the amorphous to microcrystalline phase transition of thin film silicon produced by PECVD
R. Martins, A. Maçarico, I. Ferreira, R. Nunes, A. Bicho and E. Fortunato 144

Characterization of SiO_xN_y films deposited from $SiCl_4$ by remote plasma-enhanced chemical vapor deposition
O. Sánchez, M.A. Aguilar, C. Falcony, J.M. Martínez-Duart and M. Hernández Vélez 149

Thermal stability of nonstoichiometric silicon nitride films made by reactive dc magnetron sputter deposition
H.P. Löbl and M. Huppertz 153

Electrical properties of ITO films prepared by tin ion implantation in In_2O_3 film
M. Sawada and M. Higuchi 157

Characterization of indium–tin oxide films by means of ion-implanted nuclear probes
H. Metzner, S. Habenicht, Th. Hahn, M. Uhrmacher, K.-P. Lieb, D. Borchert, R. Job and W.R. Fahrner 161

Evaluation of adhesion strength of Ti films on Si(100) by the internal stress method
A. Kinbara, E. Kusano, T. Kamiya, I. Kondo and O. Takenaka 165

A model for stress in thin layers induced by misfitting particles. An origin for growth stress
J.-D. Kamminga, Th.H. de Keijser, R. Delhez and E.J. Mittemeijer 169

AES, AFM and TEM studies of NiCr thin films for capacitive humidity sensors
L.I. Belič, K. Požun and M. Remškar 173

Modelling conduction in asymmetrical discontinuous metal thin films
J.E. Morris and F. Wu 178

RHEED study of Nb thin film growth on α-Al_2O_3 (0001) substrate
K. Mašek and V. Matolín 183

Electromigration in gold thin films
M. Aguilar, A.I. Oliva, P. Quintana and J.L. Peña 189

Ellipsometrical studies on the Au/Si(111) system
K. Mümmler and P. Wissmann 193

Structure and elastic properties of thin alloyed gold films
M.G. Beghi, C.E. Bottani, L. Guzman, T. Lafford, N. Laidani, P.M. Ossi and B.K. Tanner 198

Electrical property on copper thin film with chromium under-layer
H. Nakai, K. Fudaba, K. Shinzawa and M. Hashimoto 202

The changes of short range ordering in amorphous silicon–carbon alloys by thermal annealing
D. Gracin, N. Radić, M. Ivanda, Ž. Andreić and B. Praček 206

Spectroellipsometry and electron spectroscopy of porous Si thin films on p^+ substrates
C. Robert, L. Bideux, B. Gruzza, M. Cadoret, T. Lohner, M. Fried, E. Vazsonyi and G. Gergely 210

Oxidation processes in hydrogenated amorphous silicon nitride films deposited by ArF laser-induced CVD at low temperatures
N. Banerji, J. Serra, P. González, S. Chiussi, E. Parada, B. León and M. Pérez-Amor 214

Structural and electrical characterisations of rapid thermal annealed thin silicon oxide films on silicon
Y.M. Chan, C.K. Choo and W.K. Choi 219

Derivation of the optical constants of thermally-evaporated uniform films of binary chalcogenide glasses using only their reflection spectra
J.M. González-Leal, E. Márquez, A.M. Bernal-Oliva, J.J. Ruiz-Pérez and R. Jiménez-Garay 223

Structure and photoinduced changes in As–S–Te bulk glasses and amorphous layers
Mir. Vlček, K. Nejezchleb, T. Wagner, M. Frumar, Mil. Vlček, A. Vidourek and P.J.S. Ewen 228

Study by transmission electron microscopy and electron diffraction of thin polyethylene films
N. Popescu-Pogrion and M. Tirnovan 232

Mirror electron microscopy investigations of thin polyethylene films subjected to high voltage
R. Godehardt, J. Heydenreich, N. Popescu-Pogrion and M. Tirnovan 235

High-resolution secondary ion mass spectrometry depth profiling of superconducting thin films
N.J. Montgomery, J.L. MacManus-Driscoll, D.S. McPhail, R.J. Chater, B. Moeckly and K. Char 237

Yttria-stabilized zirconia obtained by MOCVD: applications
G. Garcia, A. Figueras, J. Casado, J. Llibre, M. Mokchah, G. Petot-Ervas and J. Calderer 241

Modulated differential scanning calorimetry experiments on film and bulk $(As_{0.33}S_{0.67})_{100-x}Y_x$, (Y = Te or I) glasses
T. Wagner, S.O. Kasap and M. Vlcek 245

Multilayers and magnetic films

Epitaxial metal/insulator superlattices of Ti–Ag/MgO grown on MgO(001) substrates
T. Kado and H. Tamai 249

Elastic behaviour of Si/Ge superlattices determined by Brillouin light scattering
A. de Bernabé, R. Jiménez, M. García-Hernández and C. Prieto 255

Multilayer coatings by continuous detonation system spray technique
I. Fagoaga, J.L. Viviente, P. Gavin, J.M. Bronte, J. Garcia and J.A. Tagle 259

Growth and microstructure of sputtered Ag/Cu multilayers
Zs. Czigány, I. Kovács and G. Radnóczi 266

Relaxation mechanism of InGaAs single and graded layers grown on (111)B GaAs
T.C. Rojas, S.I. Molina, A. Sacedón, F. Valtueña, E. Calleja and R. García 270

Investigation of ion beam mixing effects in Ta/Pd bilayers deposited on Si
N. Bibić, M. Milosavljević, D. Peruško and C. Jeynes 274

Microstructural modification in Co/Cu multilayers prepared by low energy ion-assisted deposition
N.D. Telling, M.D. Crapper, D.R. Lovett, S.J. Guilfoyle, C.C. Tang and M. Petty 278

Preparation of a new tetragonal copper oxynitride phase by reactive magnetron sputtering
A. von Richthofen, R. Domnick, R. Cremer and D. Neuschütz 282

Magnetic vortices and pinning in thin films and superlattices
J.I. Martín, M. Vélez, E.M. González and J.L. Vicent 285

Control of crystallographic and magnetic texture in dc-magnetron sputtered Co–Cr on flexible PET substrate
H. te Lintelo and P. Lippens 290

Preparation and characterisation of finemet amorphous magnetic thin films with enhanced Cu content
Z. Pászti, I. Szabó, É. Kisdi-Koszó, G. Petö, Z.E. Horváth, E. Zsoldos and L. Guczi 294

Magnetic domain structure of Co/Ni(110)
H.M. Zhang and Y. Li 298

Magnetostriction in a single-crystal $TbFe_2$ film
M. Ciria, J.I. Arnaudas, C. Dufour, V. Oderno, K. Dumesnil and A. del Moral 303

Magnetic and electrical transport properties of Fe/Zr and Fe/Ti multilayers
T. Stobiecki, M. Czapkiewicz, M. Kopcewicz, R. Żuberek and F.J. Castano 306

Growth, structure, and magnetism of W and Fe/W thin films on Al_2O_3
Y. Li, C. Polaczyk and D. Riegel 310

X-ray Magnetic Circular Dichroism study of vanadium in thin films (V/Ag(100) and V/Fe(100)) and alloys ($Fe_{0.82}V_{0.18}$/Au(111))
Finazzia, P. Bencok, K. Hricovini, F. Yubero, F. Chevrier, E. Kolb, G. Krill, M. Vesely, C. Chappert and J.-P. Renard 314

Optical coatings

New transparent conducting $ZnO–In_2O_3–SnO_2$ thin films prepared by magnetron sputtering
T. Minami, T. Kakumu, K. Shimokawa and S. Takata 318

Optical properties of zinc oxynitride thin films
M. Futsuhara, K. Yoshioka and O. Takai 322

Preparation of transparent conducting $Zn_2In_2O_5$ films by d.c. magnetron sputtering
T. Minami, T. Kakumu, Y. Takeda and S. Takata 326

Quantum confinement effects on $Cd_{1-x}Ni_xTe$ sputtered films
O. Alvarez-Fregoso, O. Zelaya-Angel and J.G. Mendoza-Alvarez 330

Thin cathodoluminescent films deposited by sol–gel process
L.Ž. Mežnar, B. Praček, B. Orel and P. Bukovec 336

Oxygen ECR stream etching of dichromated gelatin films
J.M. Villalvilla, J. Crespo, J.A. Quintana, C. Santos and J.A. Valles-Abarca 340

Diffraction gratings in dry developed dichromated gelatin films
J.A. Quintana, P.G. Boj, J. Crespo, J.A. Vallés-Abarca and J.M. Villalvilla 343

Deposition of silicon oxinitride films from hexamethyldisilizane (HMDS) by PECVD
R. González-Luna, M.T. Rodrigo, C. Jiménez and J.M. Martínez-Duart 347

Advanced materials

Corrosion of TiN, (TiAl)N and CrN hard coatings produced by magnetron sputtering
L. Cunha, M. Andritschky, L. Rebouta and R. Silva 351

Field emission from amorphous diamond films prepared by filtered arc deposition
X. Wang, J.P. Zhao, Z.Y. Chen, S.Q. Yang, T.S. Shi and X.H. Liu 356

a-C(:H) and a-CN_x(:H) films deposited by magnetron sputtering and PACVD
L. Nobili, P.L. Cavallotti, G. Coccia Lecis, G. De Ponti and C. Lenardi 359

Calcium phosphate coatings grown at different substrate temperatures by pulsed ArF-laser deposition
B. Mayor, J. Arias, S. Chiussi, F. Garcia, J. Pou, B. León Fong and M. Pérez-Amor 363

XPS/UPS studies of conducting polymers: exchange doping of dye molecules into polymer matrix
H. Kato, S. Takemura and Y. Nakajima 367

Improvement of Ta filament for diamond CVD
T. Tsutsumoto 371

Deposition time influence on cubic boron nitride thin films by tuned rf magnetron sputtering
S. Gimeno, J.C. Muñoz and A. Lousa 376

Deposition of carbon nitride thin films by arc ion plating
O. Takai, Y. Taki and T. Kitagawa 380

Structure, composition and tribological properties of carbon nitride films
A. Czyzniewski, W. Precht, M. Pancielejko, P. Myslinski and W. Walkowiak 384

Hydrocarbon films inhibit oxygen permeation through plastic packaging material
E.M. Moser, R. Urech, E. Hack, H. Künzli and E. Müller 388

Deposition of hydroxyapatite thin films by excimer laser ablation
J.M. Fernández-Pradas, G. Sardin, L. Clèries, P. Serra, C. Ferrater and J.L. Morenza 393

Characterization of diamond-like carbon by Raman spectroscopy, XPS and optical constants
C. Mößner, P. Grant, H. Tran, G. Clarke, D.J. Lockwood, H.J. Labbé, B. Mason and I. Sproule 397

Diamond-like nanocomposite coatings for low-wear and low-friction applications in humid environments
D. Neerinck, P. Persoone, M. Sercu, A. Goel, C. Venkatraman, D. Kester, C. Halter, P. Swab and D. Bray 402

Industrial applications and hard coatings

Chemical instability of the target surface during DC-magnetron sputtering of ITO-coatings
P. Lippens, A. Segers, J. Haemers and R. De Gryse 405

A comparison of the DC conduction properties in evaporated cadmium selenide thin films using gold and aluminium electrodes
A.O. Oduor and R.D. Gould 409

Transparent and conducting ZnO(:Al) films deposited by simultaneous RF- and DC-excitation of a magnetron
K. Ellmer, R. Cebulla and R. Wendt 413

Amorphous alloy formation and thickness dependent growth of Gd–silicides in solid phase thin film reaction
G.L. Molnár, G. Petõ, E. Zsoldos, N.Q. Khánh and Z.E. Horváth 417

Thin films applied to integrated optical position-sensitive detectors
E. Fortunato, F. Soares, G. Lavareda and R. Martins 421

PbSe photodetector arrays for IR sensors
A. Muñoz, J. Meléndez, M.C. Torquemada, M.T. Rodrigo, J. Cebrián, A.J. de Castro, J. Meneses, M. Ugarte, F. López, G. Vergara, J.L. Hernández, J.M. Martín, L. Adell and M.T. Montojo 425

Electrical characterization of a thin film tin oxide sensor array for VOCs detection
J. Gutiérrez, J. Getino, M.C. Horrillo, L. Arés, J.I. Robla, C. García and I. Sayago 429

The effects of oxygen doping and annealing on the surface and bulk electrical conductivity in planar copper phthalocyanine thin films for gas-sensing applications
Q. Zhou and R.D. Gould 432

A study of the response rate to nitrogen dioxide exposure in metal phthalocyanine thin film sensors
Q. Zhou and R.D. Gould 436

Ion-plated discontinuous thin film strain gauges
E. Broitman and R. Zimmerman 440

Influences of dopants on the electronic structure of SnO_2 thin films
X. Cao, L. Cao, W. Yao and X. Ye 443

New effective medium approach to optical response in non-random arrays
A.V. Radchik, P. Moses, I.L. Skryabin and G.B. Smith 446

New development in superhard coatings: the superhard nanocrystalline-amorphous composites
S. Vepřek 449

Recent progress in the measurement of the thermal properties of hard coatings
C. Martinsons and M. Heuret 455

Phase transformation in sputtered Ti–SS alloy film during plasma nitriding
J. Musil, V. Ježek, M. Benda and J. Vlček 458

Microstructural modification of TiN deposited by magnetron ion plating: Influence of magnetic field configuration
M. Zlatanović, N. Popović, Ž. Bogdanov, R. Beloševac, A. Kunosić and B. Goncić 463

Synthesis of iron–tungsten alloy on mild steel by laser surface alloying
Y. Isshiki, K. Mizumoto and M. Hashimoto 468

Improvement of tribological properties by ion implantation
J.I. Oñate, F. Alonso and A. García 471

Depth-profiling via X-Ray photoemission and Auger spectroscopies of N^+ implanted tungsten carbides grown on the Ti–6Al–4V alloy
N. Laidani, C. Dorigoni, A. Miotello, L. Calliari, G. Scarel and M. Sancrotti 477

Tribological properties of calcium fluoride-based solid lubricant coatings at high temperatures
Y. Pauleau, P. Juliet and R. Gras 481

Influence of plasma nitriding on mechanical and tribological properties of steel with subsequent PVD surface treatments
B. Škorić, D. Kakaš and T. Gredić 486

IBAD SIN_x coating: preparation and tribological properties
F. Cerný, J. Suchánek and V. Hnatowicz 490

Electrochemical modifications at the nanometer scale on Si(100) surfaces with Scanning Tunnelling Microscopy
G. Abadal, F. Pérez-Murano, N. Barniol and X. Aymerich 493

The gas-phase condensation method for the preparation of quantum-sized ZnS nanoparticles
J.C. Sánchez-López and A. Fernández 497

Author Index of Volume 317 500

Subject Index of Volume 317 502

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